U. S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE Complete if Known RADEM! Application Number 10/684,120 October 10, 2003 **INFORMATION DISCLOSURE** Christof Baur, et al. Applicant(s) (本) STATEMENT BY APPLICANT Unknown (use as many sheets as necessary) Art Unit Examiner Name 🛴 🤚 Unknown SHEET OF Attorney Docket Number 34003.55 1

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